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Coupling Silver Iodide Emitters to Aluminum Plasmons

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a nanostructured. We investigate the coupling of AgI to plasmon modes, choosing aluminum (Al) s owing to its low damping in the blue spectral range, in contrast to silver or gold. We investigate, 6 first, an extended Al thin film overcoated with a SiO₂ spacer layer and a AgI film. Spectroscopic 7 surface plasmon resonance measurements confirm the anticrossing in the system's dispersion 8 diagram, with a large energy splitting of about 140 meV, indicative of the onset of strong coupling.



9 Second, we probe Al nanodisks overcoated with SiO_2 and AgI, spectrally shifting the dipolar Al plasmon over the AgI absorption line 10 by lithographically controlling the disk diameter. From extinction spectra, we again observe anticrossing, with an energy splitting of 11 about 100 meV. Our results demonstrate that AgI is an easily fabricated and structured emitter, which in combination with Al forms 12 an attractive platform to achieve an efficient plasmon–exciton coupling in the blue spectral range.

13 INTRODUCTION

14 The coupling of light emitters and plasmon modes leads to a 15 vast range of effects, from the modification of absorption and 16 emission rates, emission statistics, and emission profiles¹⁻³ to 17 strong coupling.^{4,5} In particular, strong coupling has attracted 18 significant attention in recent years, involving mainly 19 molecules^{6,7} or semiconductor quantum dots.^{8,9} Although 20 most approaches have relied on the classical plasmonic 21 materials such as silver and gold, some studies that focused 22 on low-wavelength emitters have turned to aluminum (Al) 23 owing to its low loss in the blue spectral range.^{10,11} In this 24 work, we show that silver iodide (AgI) is an efficient blue 25 emitter that can be conveniently tailored to a target geometry 26 by iodizing silver structures. We couple AgI to Al plasmons, 27 evidencing the onset of strong coupling.

AgI, well known from early photography,¹² shows narrow absorption and emission features at room temperature, with a band edge slightly below 3 eV. Fabricated by the iodization of sliver, the gradual change from the plasmonic (silver) to the excitonic (AgI) behavior has been probed spectroscopically.¹³ The combination of AgI and plasmons has however been addressed in just a few studies, including spherical silver s nanoparticles, where coupling leads to Fano lineshapes in absorbance spectra.¹⁴ On the other hand, the plasmon peaks of gold nanoparticles were found to just experience spectral shifts the presence of AgI, due to the significant energy difference of gold plasmons and AgI absorption.¹⁵

Here, we couple AgI to the surface plasmons of Al in two 41 different systems. We investigate, first, a thin AgI layer that is 42 deposited onto an Al thin film covered with a SiO_2 spacer 43 layer. Second, we probe the regular arrays of Al nanodisks 44 covered with SiO_2 and AgI. The nanodisk diameter is varied, 45 thus gradually changing the resonance positions of the Al 46 localized surface plasmon resonance (LSPR). We observe clear 47 coupling signatures in optical spectra that fit very well to simulations, based on the transfer matrix approach and a 48 simple coupled oscillator model. In particular, we find a large 49 energy splitting of about 140 meV in the thin film system, 50 corresponding to the onset of strong coupling.

MATERIALS AND METHODS

Silver lodide. AgI is a wide-gap semiconductor prepared by 53 iodizing a silver thin film either structured or unstructured. For 54 spectroscopic characterization, silver (island) films with 2 and 55 5 nm mass thicknesses are evaporated onto a quartz substrate 56 by physical vapor deposition at about 5×10^{-6} mbar base 57 pressure. The films are then exposed to the iodine vapor from a 58 5 mm-sized solid iodine crystal at about 4 cm distance at room 59 temperature and ambient pressure for 10 min. The conversion 60 of the Ag cubic phase to the AgI wurtzite phase (β -AgI) leads 61 to a 4× volume enhancement¹⁶ and thus nominal average AgI 62 thicknesses of about 8 and 20 nm, respectively, as confirmed by 63 an atomic force microscope. The films are basically 64 discontinuous (on a 10 nm scale), reflecting the island 65 characteristic of the silver thin films.

Optical absorbance spectra of AgI thin films with thicknesses 67 of 8 and 20 nm on quartz plates are depicted in Figure 1a. The 68 fl spectra indicate a sharp excitonic peak $(W_{1,2})$ at 2.94 eV and a 69 small excitonic peak $(W_3$, not shown) at 3.77 eV.¹⁷ The direct 70 band gap of AgI thin films is determined by a Tauc plot,¹⁷ 71 yielding a value of 2.85 eV for both film thicknesses. The Tauc 72 plot of AgI thin films is shown in Figure S1 in the Supporting 73 Information. 74

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Figure 1. (a) Absorbance spectra of AgI layers on a quartz substrate, with thicknesses of 8 nm (blue) and 20 nm (orange). (b) Real (n, red) and imaginary parts (k, black) of the dielectric function of AgI as derived from (a).

The dielectric function of AgI was derived from the r6 absorbance measurements on 8 and 20 nm thick AgI films. The derivation of the dielectric function is explained in the Supporting Information (see also Figure S2). The dielectric permittivity was presumed to be a sum of Lorentzian terms, whose amplitudes were adjusted to fit the simulated absorbance spectra, as calculated by the transfer matrix formalism (see below) to the experimental data (Figure 1a). The derived refractive index in Figure 1b is close to the published values.¹⁸

Preparation of Extended Al–SiO₂–Agl Films. A 20 nm 86 thick Al thin film is evaporated onto a quartz substrate. The Al 87 thickness is chosen for efficient surface plasmon excitation in 88 the blue spectral range.¹⁹ To avoid chemical reactions between 89 Al and iodine and to prevent emitter quenching, a protective 90 layer of 10 nm SiO₂ is evaporated onto the Al thin film. Then, 91 a thin layer of Ag (2 or 5 nm mass thickness) is evaporated and 92 iodized as described above. The mass thicknesses of the 93 resulting AgI layers are 8 and 20 nm.

Fabrication of SiO₂-Agl-Covered Al Nanodisk Arrays. Arrays of disk-shaped Al nanoparticles were fabricated by electron beam lithography on an indium tin oxide (ITO)rocated glass substrate. First, a 100 nm thick layer of poly(methyl methacrylate) (PMMA) resist (Allresist ARP 96 671.01) is spin-coated onto the substrate and annealed for 15 no min at 180 °C (Figure 2a). The resist is exposed by the



Figure 2. Electron beam lithography of $Al-SiO_2-AgI$ nanodisks. (a) PMMA coating of the ITO-covered glass substrate, (b) electron beam exposure and development, (c) Al deposition and PMMA liftoff, (d) SiO₂ spacer layer deposition, (e) Ag evaporation, and (f) Ag iodization.

101 electron beam in a RAITH eLiNE+ lithography system. The 102 applied pattern consists of circular holes with diameters 103 ranging from about 50 to 90 nm, arranged in a quadratic array 104 with a 200 nm pitch. The area of each array is $100 \times 100 \ \mu m^2$. 105 After exposure, the samples are chemically developed (30 s 106 Allresist ARP 600-55 mixed 2:1 with IPA, 30 s stopper Allresist 107 ARP 600-60). Subsequently, 20 nm Al is evaporated by 108 physical vapor deposition. Following 10 nm of SiO₂, 3.5 nm Ag 109 is deposited and iodized, forming a AgI layer of about 14 nm mass thickness. Finally, the residual resist is removed by liftoff 110 in acetone (Figure 2b-f). 111

SPR Spectroscopy. The plasmon-emitter coupling in the 112 Al–SiO₂–AgI film system is measured by surface plasmon 113 resonance (SPR) spectroscopy in the Kretschmann–Raether 114 prism coupling configuration (see Figure 3a). Light reflection 115 f3



Figure 3. Sketch of the SPR setup with a rotating prism, for about (a) $\theta_0 = 45^\circ$ and (b) $\theta_0 = 80^\circ$.

is measured for varying incident angles, controlled by the 116 rotation of the prism supporting the sample (Figure 3b). The 117 whole setup is placed inside a spectrophotometer (Varian Cary 118 SE) and reflection spectra are recorded for incidence angles θ_0 119 ranging from 45° to about 80°. The total internal reflection of 120 the bare prism was used as reference for a reflectivity of 1. 121 From the recorded spectra, we deduced the reflectivity as a 122 function of photon energy and in-plane wavenumber, k = 123 $nk_0 \sin \theta_0$, where k_0 is the vacuum wavenumber and n is the 124 refractive index of the prism. 125

Optical Extinction Spectroscopy. The optical extinction 126 of the covered Al nanodisk arrays is deduced from transmission 127 spectra acquired with a spectrophotometer (Zeiss MMS1) 128 fiber-coupled to an optical microscope (Zeiss Axioskop, 129 objective 2.5×, numerical aperture 0.075) that is equipped 130 with a halogen lamp. The useable spectral range is 400-1100 131 nm with a spectral resolution of about 3 nm. 132

Transfer Matrix Simulations. SPR spectra are calculated 133 by a standard transfer matrix formalism with light incident 134 from a SiO₂ (n = 1.46) half space. Then, layers of 20 nm Al 135 (dielectric function from ref 10, 20), 10 nm SiO₂ (n = 1.46), 136 and 8 nm or 20 nm AgI (for dielectric function, see Figure 1b) 137 followed by an air half space (n = 1) are simulated. Further 138 simulation schemes are discussed below. 139

RESULTS AND DISCUSSION

We first turn to the film system to investigate the coupling 141 between surface plasmons at the Al–SiO₂ interface and 142 excitons in 8 and 20 nm thick AgI layers. The thicker the 143 AgI layer, the higher is the number of excitable AgI 144 nanocrystals and thus stronger coupling is expected. 145

In Figure 4a,b, the measured reflectivity as a function of 146 f4 photon energy and in-plane wavenumber k are plotted for the 147 AgI thicknesses of 8 and 20 nm, respectively. The 148 corresponding transfer matrix simulations are shown in Figure 149 4c,d. The cyan dots in all figures indicate the reflection minima 150 of the experimental data, determined by searching the 151 corresponding reflection minimum for a fixed angle of 152 incidence. We find excellent agreement between the experi- 153 ment and simulation and observe a clear anticrossing²¹⁻²³ 154 between the surface plasmon dispersion and the AgI resonance 155 at 2.94 eV. The experimentally recorded, angle-dependent 156

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Figure 4. (a, b) Measured and (c, d) simulated reflection diagrams of an Al–SiO₂–AgI layer system with (a, c) 8 nm and (b, d) 20 nm AgI thicknesses. The cyan dots give the reflection minima as derived from the experimental data. The blue and red lines indicate the light lines in the air and the quartz substrate, respectively. In (b) and (d), only part of the anticrossing region can be observed. Due to the high refractive index of AgI, the surface plasmon dispersion is shifted to larger kvalues, thus preventing coupling to light at wavenumbers close to and right of the red line.

157 reflection spectra that were used to derive Figure 4a,b are 158 shown in the Supporting Information (Figure S3).

For a better understanding of the coupling, we now model to the experimental results by a simple system of two coupled, tal damped classical oscillators,²³ corresponding to the excitonic AgI resonance with fixed resonance energy and to the surface plasmon resonance of the Al layer. For the latter, the resonance the energy is described as a function of the in-plane wavenumber, sproximated by fitting a third-order polynomial to the experimental reflection minima, excluding the energy region for of the AgI exciton around 2.9 eV. When neglecting the losses, the resonance energies of the system of coupled oscillators can be analytically described as²²⁻²⁴

$$\omega_{\rm U,L}^2 = \frac{1}{2}(\omega_1^2 + \omega_2^2) \pm \frac{1}{2}\sqrt{(\omega_1^2 + \omega_2^2)^2 + 4\Gamma^2\omega_1\omega_2}$$
170 (1)

171 where ω_1 and ω_2 are the resonance energies of the uncoupled 172 oscillators representing the AgI exciton (index 1) and the 173 surface plasmon resonance (index 2) and Γ describes the (AgI 174 thickness-dependent) energy splitting. However, here the 175 oscillators are strongly damped and, as detailed below, this 176 relation only describes roughly the observed resonances.

With Γ fitted to the experimental data, the dispersions (as 177 178 noted, for the lossless case) are plotted as the green curves in Figure 5 for the layer systems with (a,c) 8 nm and (b,d) 20 nm 179 AgI thicknesses. For comparison, the black/white dashed lines 180 display the uncoupled oscillators. The green curves perfectly 181 182 follow the experimental reflection minima (taken from Figure 4), plotted by the cyan dots, indicating that the plasmon-AgI 183 coupling is very well described by the simple oscillator model. 184 185 We deduce energy splittings of about 100 and 140 meV for the 186 AgI thicknesses of 8 and 20 nm, respectively.

Despite the rather large energy splitting, we analyze our data further, as great care is advisable for plasmonic systems when las claiming strong coupling, as illustrated in recent studies.^{9,25,26} Po First, we deduce the spectral widths of the surface plasmon and



Figure 5. Model calculations of a system of two coupled oscillators. (a, b) Amplitude of the surface plasmon oscillator and (c, d) amplitude of the AgI oscillator, corresponding to Al–SiO₂–AgI layer systems with (a, c) 8 nm AgI and (b, d) 20 nm AgI thicknesses. The dashed black/white lines indicate the dispersion relations of the uncoupled oscillators. The green curves show the calculated resonance positions of the coupled system. The cyan dots indicate the experimental reflection minima, as shown in Figure 4. The blue and red lines are the light lines in air and the quartz substrate, respectively. The insets depict the energy dependence of the oscillator amplitudes at wavenumbers of (a, c) 17.6 μ m⁻¹ and (b, d) 21.2 μ m⁻¹, respectively.

the AgI at resonance, as outlined in Figures S4 and S5a. For 191 the plasmon, we analyze the reflection data in Figure 4 and 192 extrapolate a fit to the off-resonance width data to the 193 resonance position. We find about 190 and 200 meV for the 194 plasmon in the Al film covered with 8 and 20 nm AgI, 195 respectively, and 60 nm for the AgI. Applying the threshold 196 criterion according to ref 4 yields an energy value slightly 197 above 140 meV, so that we conclude that the sample with 20 198 nm AgI is at the onset of strong coupling.

Then, we display separately the amplitudes of the plasmon 200 and the AgI oscillators as simulated with losses included, see 201 the color plots in Figure 5a,c (8 nm AgI) and Figure 5b,d (20 202 nm AgI). For both AgI thicknesses, the splitting of the plasmon 203 oscillator into upper and lower energy branches is evident 204 (Figure 5a,b and insets), with maxima well described by the 205 green curves. However, the AgI oscillator amplitudes in Figure 206 5c,d display only weak energy splitting (AgI thickness 20 nm, 207 Figure 5d). Here, despite the large splitting value, strong 208 coupling is hampered by the relatively large damping of the 209 AgI and the surface plasmon oscillator with a photon energy of 210 2.9 eV. 211

In more physical terms, it is the surface plasmon that is 212 directly and strongly excited by light in the SPR geometry. The 213 surface plasmon efficiently excites the AgI to high amplitude 214 (in the oscillator model) and absorption around its resonance 215 energy, in turn (corresponding to the weak coupling limit) 216 leading to stronger damping and thus reducing the plasmon 217 amplitude. The AgI oscillator thus has a stronger or even the 218 largest amplitude at the resonance of the surface plasmon 219 oscillator. The amplitude of the latter is, however, reduced due 220 to the energy lost by driving the AgI. This leads to a more 221 obvious splitting of the surface plasmon dispersion as 222 compared to the AgI dispersion. Only with increasing coupling 223 strength, a clear branch splitting is observed for both 224

225 oscillators. In Figure 5c) (inset), we observe just a shallow 226 minimum between the amplitude peaks of upper and lower 227 branches, while in Figure 5d (inset) this minimum is somewhat 228 more pronounced. We thus conclude that we observe the onset 229 of strong coupling and that optimized samples could operate in 230 this regime, as there is a strong dependence of the energy 231 splitting on SiO₂ and AgI thickness (Figure S6).

232 With larger splitting, the strongest excitation of AgI by the 233 plasmon shifts further away from the AgI resonance energy; 234 thus, the AgI splitting gets larger as well. It is expected to reach 235 the values of the plasmon oscillator for even larger coupling 236 strength. To clarify this, Figure S7 depicts the calculated 237 energy splitting of the two coupled oscillators with different damping values (similar to the surface plasmon and AgI) as a 238 function of coupling strength. 239

We now turn to the coupling of AgI and Al nanodisk LSPRs. 240 241 The Al nanodisks have diameters of about 50-90 nm and 242 heights of 20 nm Al, 10 nm SiO₂, and 13.5 nm AgI. The disk 243 diameter tunes the spectral position of the LSPR, which was 244 chosen to overlap with the AgI W_{1,2} exciton peak. The 245 measured diameter-dependent extinction spectra are depicted 246 in Figure 6a,b. With increasing disk diameter, the LSPR peak

energy / eV

diameter (nm)

Figure 6. (a) Color map and (b) line plots of the experimental extinction spectra for SiO2-AgI-covered nanodisk arrays with different particle diameters (compare Figure S8). The arrow in (b) indicates extinction due to uncoupled AgI. (c) Color map of the simulated extinction cross section, applying the quasistatic model. (d) Coupled oscillator model calculation showing the Al LSPR amplitude. The dashed black/white lines indicate the resonance energies of the two uncoupled oscillators. The green lines plot the resonance energies of the coupled oscillators. The cyan dots indicate the extinction

diameter / nm

maxima of the experimental spectra in (a), (b).

247 red-shifts and shows anticrossing at the AgI exciton line, 248 indicative of coupling. The Al nanodisk extinction spectra for 249 different disk diameters before and after covering with SiO₂ are

250 shown in Figure S8 to illustrate the effect of SiO_2 in this 251 system. The spectral width as exemplified for a 90 nm diameter 252 disk is 370 meV, as shown in Figure S5b. To simulate the observed spectral data, we apply a 2.53

254 quasistatic description, modeling the Al nanodisks as oblate 255 ellipsoids (closely approximating the disk shape) in a 256 homogeneous environment with an effective permittivity 257 derived from equal contributions from AgI, ITO, and SiO₂ 258 to achieve the best fit. The polarizability of an ellipsoid in a 259 homogeneous external field is given by

$$\alpha = \varepsilon_{\rm e} V \frac{\varepsilon_{\rm m} - \varepsilon_{\rm e}}{\varepsilon_{\rm e} + A(\varepsilon_{\rm m} - \varepsilon_{\rm e})}$$
(2) 260

 ε_e is the permittivity of the environment (AgI, see Figure 1b)), 261 $\varepsilon_{\rm m}$ is the frequency-dependent metal (Al) permittivity,²⁰ V is 262 the particle volume, and A is the ellipsoidal particle shape 263 factor corresponding to the disk shape in the experiment. The 264 extinction cross section $c_a \propto \Im(\alpha)$, where $\Im(\alpha)$ is the 265 imaginary part of the polarizability, is plotted in Figure 6c. 266 Despite the coarse model, the similarity between the model 267 and the experiment is striking. 268

With this in mind, we model the experimentally observed 269 spectral behavior by two coupled oscillators, similar to the 270 model used for the Al-SiO2-AgI film system. As light 271 interaction and extinction are dominated by the LSPR, we plot 272 in Figure 6d the oscillator amplitude only for the Al LSPR. 273 Again, we find good accordance with the experimental results 274 in Figure 6a and deduce an energy splitting of 100 meV. A 275 closer view on the resonance region around 2.9 eV shows that 276 in the experiment, some extinction is present within the 277 anticrossing region, evident as the shoulder in the line spectra 278 in Figure 6b, marked by the arrow. This is most likely due to 279 some uncoupled AgI fraction, as to be expected from our 280 sample geometry, compare with Figure 2. 281

CONCLUSIONS

Combining AgI and Al, we investigated the coupling of 283 plasmons and excitons in the blue spectral range, demonstrat- 284 ing a large energy splitting of about 140 meV. We fabricated, 285 on the one hand, a thin film stack involving surface plasmons 286 and, on the other hand, nanodisks involving LSPRs, 287 demonstrating the versatility of a fabrication scheme that 288 simply relies on the iodization of silver. Overall, our results 289 show that the coupling of AgI and Al plasmons can lead to the 290 onset of strong coupling. It is thus to be expected that strong 291 coupling can be achieved by optimizing the sample geometry 292 and material parameters. For example, stronger coupling in 293 Al-SiO₂-AgI systems is to be expected from increased AgI 294 thickness or reduced SiO₂ thickness. In general, coupling AgI 295 to Al plasmons provides a platform that could contribute to an 296 increased control for nanoscale light/matter interaction, 297 including applications in low-threshold lasers,²² quantum 298 information processing,²⁷ and single photon sources.² 299

- ASSOCIATED CONTENT 300
- Supporting Information

The Supporting Information is available free of charge at 302 https://pubs.acs.org/doi/10.1021/acs.jpcc.0c09025. 303

Tauc plots of AgI; dielectric function of AgI; comparison 304 of calculated and measured AgI absorbance spectra; SPR 305 reflection spectra; resonance width of the Al surface 306 plasmon; resonance width of AgI and the Al LSPR; 307 energy splitting of the surface plasmon dispersion as a 308 function of SiO₂ and AgI thickness; amplitudes as a 309 function of energy and coupling constant of two 310 coupled, damped oscillators; and extinction spectra of 311 nanodisk arrays without and with SiO_2 layer (PDF) 312

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332 Author Contributions

333 J.R.K. and A.H. conceived the idea and supervised the project. 334 R.T. introduced AgI for this project and fabricated all samples. 335 A.H. and H.D. have participated in sample preparation. R.T. 336 carried out the SPR spectroscopy in the Kretschmann-Raether 337 configuration and performed all optical measurements. All 338 calculations were performed by A.H after discussion with R.T., 339 H.D., and J.R.K. The first manuscript was prepared by R.T. and 340 edited and finalized by all authors. The final version of the 341 figures was done by A.H.

342 Notes

343 The authors declare no competing financial interest.

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348 **ABBREVIATIONS**

349 AgI, silver iodide; Al, aluminum; ITO, indium tin oxide; LSPR, 350 localized surface plasmon resonance; PMMA, poly(methyl 351 methacrylate); SPR, surface plasmon resonance

REFERENCES 352

(1) Schlücker, S. Surface-enhanced Raman spectroscopy: Concepts 353 354 and chemical applications. Angew. Chem., Int. Ed. 2014, 53, 4756-355 4795.

(2) Lozano, G.; Louwers, D. J.; Rodriguez, S. R. K.; Murai, S.; 356 357 Jansen, O. T. A.; Verschuuren, M. A.; Rivas, J. G. Plasmonics for solid-358 state lighting: enhanced excitationand directional emission of highly 359 efficient light sources. Light Sci. Appl. 2013, 2, No. e66.

360 (3) Schokker, A. H.; Koenderik, A. F. Statistics of randomized plasmonic lattice lasers. ACS Photonics 2015, 2, 1289-1297. 361

(4) Törmä, P.; Barnes, W. L. Strong coupling between surface 362 363 plasmon polaritons and emitters: a review. Rep. Prog. Phys. 2015, 78, 364 No. 013901.

(5) Pelton, M.; Storm, S. D.; Leng, H. Strong coupling of emitters to 365 366 single plasmonic nanoparticles: exciton-induced transparency and 367 Rabi splitting. Nanoscale 2019, 11, 14540-14552.

(6) Bellessa, J.; Bonnand, C.; Plenet, J. C. Strong coupling between 368 369 surface plasmons and excitons in an organic semiconductor. Phys. Rev. 370 Lett. 2004, 93, No. 036404(1).

(7) Hakala, T. K.; Toppari, J. J.; Kuzyk, A.; Pettersson, M.; 371 372 Tikkanen, H.; Kunttu, H.; Törmä, P. Vacuum Rabi splitting and 373 strong coupling dynamics for surface plasmon polaritons and 374 Rhodamine 6G molecules. Phys. Rev. Lett. 2009, 103, No. 053602(1).

(8) Santhosh, K.; Bitton, O.; Chuntonov, L.; Haran, G. Vacuum 375 Rabi splitting in a plasmonic cavity at the single quantum emitter 376 limit. Nat. Commun. 2016, 7, No. 11823. 377

(9) Shlesinger, I.; Monin, H.; Moreau, J.; Hugonnin, J. P.; Dufour, 378 M.; Ithurria, S.; Vest, B.; Greffet, J. J. Strong coupling of nanoplatelets 379 and surface plasmons on a gold surface. ACS Photonics 2019, 6, 380 2643-2648. 381

(10) Lawrie, B. J.; Kim, K. W.; Norton, D. P.; Haglund, R. F., Jr 382 Plasmon-Exciton hybridization in ZnO quantum-well Al nanodisc 383 heterostructures. Nano Lett. 2012, 12, 6152-6157. 384

(11) Knight, M. W.; King, N. S.; Liu, L.; Everitt, H. O.; Nordlander, 385 P.; Halas, N. J. Aluminum for plasmonics. Nano Lett. 2014, 8, 834- 386 840. 387

(12) Burley, G. Photolytic behavior of silver iodide. J. Res. Natl. Bur. 388 Stand., Sect. A 1963, 67, 301-307. 389

(13) Mohan, D. B.; Sreejith, K.; Sunandana, C. S. Surface plasmon- 390 exciton transition in ultra-thin silver and silver iodide films. Appl. Phys. 391 B 2007, 89, 59-63. 392

(14) Andreeva, O. V.; Sidorov, A. I.; Stasel'ko, D. I.; Khrushcheva, T. 393 A. Synthesis and Optical Properties of Hybrid "Plasmon-Exciton" 394 Nanostructures Based on Ag-AgI in Nanoporous Silica Glass. Phys. 395 Solid State 2012, 54, 1293-1297. 396

(15) El-Kouedi, M.; Foss, C. A. Optical Properties of Gold-Silver 397 Iodide Nanoparticle Pair Structures. J. Phys. Chem. B 2000, 104, 398 4031 - 4037.399

(16) Bashouti, M. Y.; Talebi, R.; Kasar, T.; Nahal, A.; Ristein, J.; 400 Unruh, T.; Christiansen, S. H. Systematic Surface Phase Transition of 401 Ag Thin Films by Iodine Functionalization at Room Temperature: 402 Evolution of Optoelectronic and Texture Properties. Sci. Rep. 2016, 6, 403 No. 21439. 404

(17) Kumar, P. S.; Dayal, P. B.; Sunandana, C. S. On the formation 405 mechanism of γ-AgI thin films. Thin Solid Films 1999, 357, 111-118. 406

(18) Cochrane, G. Some optical properties of single crystals of 407 hexagonal silver iodide. J. Phys. D: Appl. Phys. 1974, 7, 748-758. 408

(19) Ono, A.; Kikawada, M.; Akimoto, R.; Inami, W.; Kawata, Y. 409 Fluorescence enhancement with deep-ultraviolet surface plasmon 410 excitation. Opt. Express 2013, 21, 17447-17453. 411

(20) McPeak, K. M.; Jayanti, S. V.; Kress, S. J. P.; Meyer, S.; Iotti, S.; 412 Rossinelli, A.; Norris, D. J. Plasmonic films can easily be better: Rules 413 and recipes. ACS Photonics 2015, 2, 326-333. 414

(21) Symonds, C.; Bonnand, C.; Plenet, J. C.; Bréhier, A.; 415 Parashkov, R.; Lauret, J. S.; Deleporte, E.; Bellessa, J. Particularities 416 of surface plasmon-exciton strong coupling with large Rabi splitting. 417 New J. Phys. 2008, 10, No. 065017(1). 418

(22) Hakala, T. K.; Rekola, H. T.; Väkeväinen, A. I.; Martikainen, J.- 419 P.; Necada, M.; Moilanen, A. J.; Törmä, P. Lasing in dark and bright 420 modes of a finite-sized plasmonic lattice. Nat. Commun. 2012, 86, 421 No. 13687. 422

(23) Novotny, L. Strong coupling, energy splitting, and level 423 crossing: A classical perspective. Am. J. Phys. 2017, 8, 1199-1202. 424 (24) Gómez, D. E.; Lo, S. S.; Davis, T. J.; Hartland, G. V. 425

Picosecond Kinetics of Strongly Coupled Excitons and Surface 426 Plasmon Polaritons. J. Phys. Chem. B 2013, 117, 4340-4346. 427 (25) Zengin, G.; Gschneidtner, T.; Verre, R.; Shao, L.; Antosiewicz, 428

T. J.; Moth-Poulsen, K.; Käll, M.; Shegai, T. Evaluating conditions for 429 strong coupling between nanoparticle plasmons and organic dyes 430 using scattering and absorption spectroscopy. J. Phys. Chem. C 2016, 431 120, 20588-20596. 432

(26) Antosiewicz, T. J.; Apell, S. P.; Shegai, T. Plasmon-exciton 433 interactions in a core-shell-geometry: From enhanced absorption to 434 strong coupling. ACS Photonics 2014, 1, 454-463. 435

(27) Hennessy, K.; Badolato, A.; Winger, M.; Gerace, D.; Atatre, M.; 436 Gulde, S.; Flt, S.; Hu, E. L.; Imamoglu, A. Quantum nature of a 437 strongly coupled single quantum dot-cavity system. Nature 2007, 445, 438 896-899. 439

(28) Cui, G.; Raymer, M. G. Quantum efficiency of single-photon 440 sources in the cavity-QED strong-coupling regime. Opt. Express 2005, 441 13, 9660-9665. 442